

# Ultrafast x-ray absorption spectroscopy of laser-excited materials

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- Introduction: time-resolved x-ray absorption spectroscopy, liquid carbon
- Bunch slicing
- ALS beamline 6.0

# Introduction: time resolved x-ray absorption spectroscopy

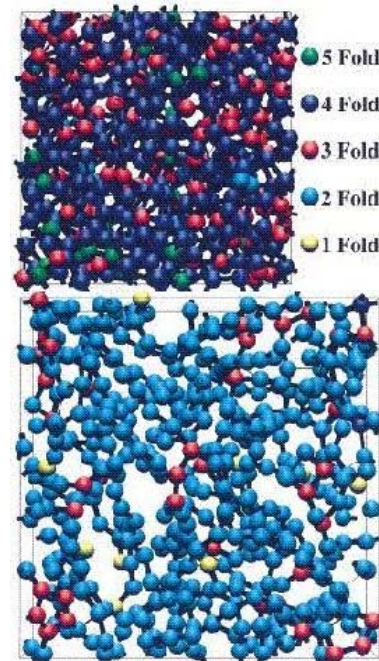
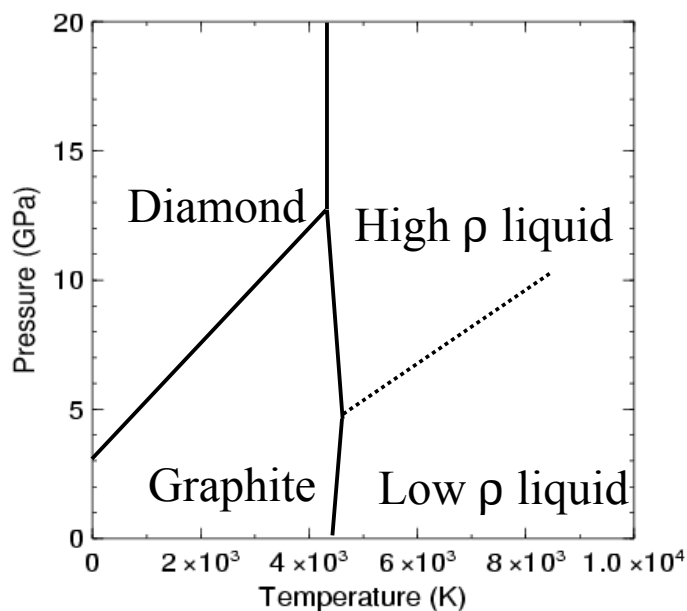


- Time-resolved Near-Edge (XANES) and Extended X-ray Absorption Fine Structure (EXAFS): use these probes of electronic states and structure with time resolution approaching molecular vibration  $\sim 100$  fs
- Applications at bend magnet BL 5.3.1: with ALS pulse duration 70 ps, streak camera  $\sim 2$  ps, slicing 100 fs
  - Phase transitions:  $\text{VO}_2$  insulator to metal (A. Cavalleri et al.)
  - Photochemistry in solution:  $[\text{Ru}^{\text{II}}(\text{bpy})_3]^{2+} \rightarrow [\text{Ru}^{\text{III}}(\text{bpy})_3]^{3+}$  (W. Gawelda poster 10.6 Wed)
  - Atomic physics:  $\text{K}^+$  (A. Belkacem et al.)
  - High temperature materials: liquid silicon, **liquid carbon** (S. Johnson thesis)
- Observe laser-induced transient states that cannot be made statically

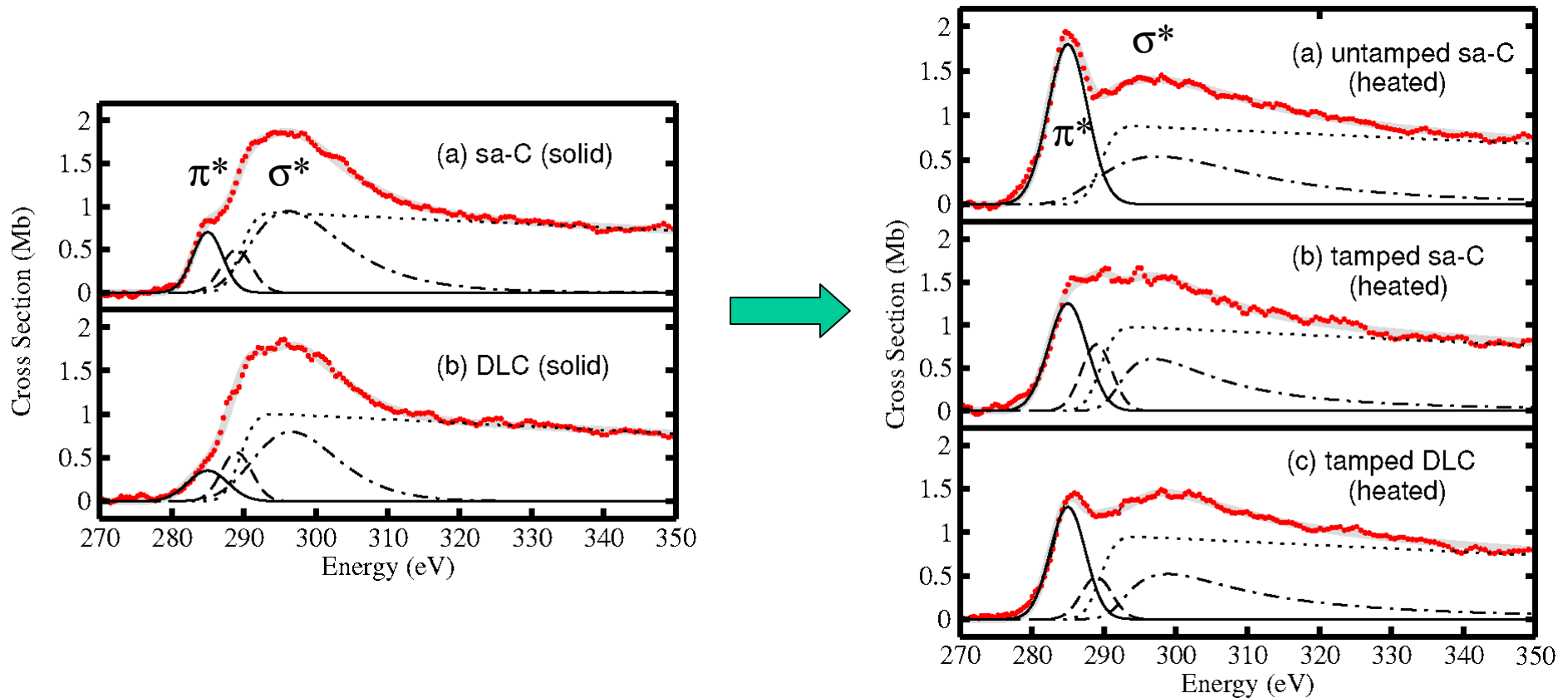
# X-ray absorption of liquid carbon



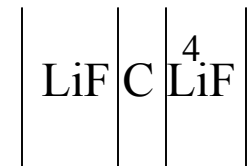
- In planets Uranus and Neptune, middle layer of  $\text{CH}_4$ ,  $\text{H}_2\text{O}$  and  $\text{NH}_3$  at high T, P.  $\text{CH}_4$  expected to be dissociated. Liquid carbon not stable ambient pressure
- Molecular dynamics calculations
  - Low density  $\rho$  liquid predominantly sp coordination, high  $\rho$  liquid mainly  $\text{sp}^3$ , Glosli and Ree, PRL 82, 4659 (1999)
  - Continuous change from sp  $\text{sp}^2$  mixture to  $\text{sp}^2$   $\text{sp}^3$  mixture as density is increased, Wu et al., PRL 89, 135701 (2002)



## Carbon K-edge spectra



- Initial sample: soft amorphous carbon  $\rho$ , 2.2 g/cm<sup>3</sup>, DLC  $\rho$ , 2.6 g/cm<sup>3</sup>,
- Heated spectrum shows increase in  $\pi^*$  resonance, decrease in  $\sigma^*$  resonance
- Tamp carbon with LiF, to keep density constant - spectra at 100 and 300 ps are the same



## K-edge spectrum of tamped carbon



Material	$\pi^*$ area	$\pi^*$ states/site	$\pi^*$ states/site calculation <sup>1</sup>
soft a-C	0.047	0.70	
DLC	0.030	0.45	
untamped liquid	0.135	2.01	
2.2 g/cc liquid	0.090	1.35	1.29
2.6 g/cc liquid	0.087	1.29	1.16

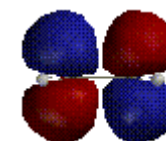
<sup>1</sup>Morris et al. Phys. Rev. B 52, 4138 (1995)

### Unoccupied $\pi$ orbitals

Ethane  $sp^3$

None

Ethylene  $sp^2$



Acetylene  $sp$



- At low density (untamped), liquid C is  $sp$  bonded
- At higher density, liquid C has mixture of different bonding, agrees with calculations
- Goals: Improved energy resolution, EXAFS sensitivity

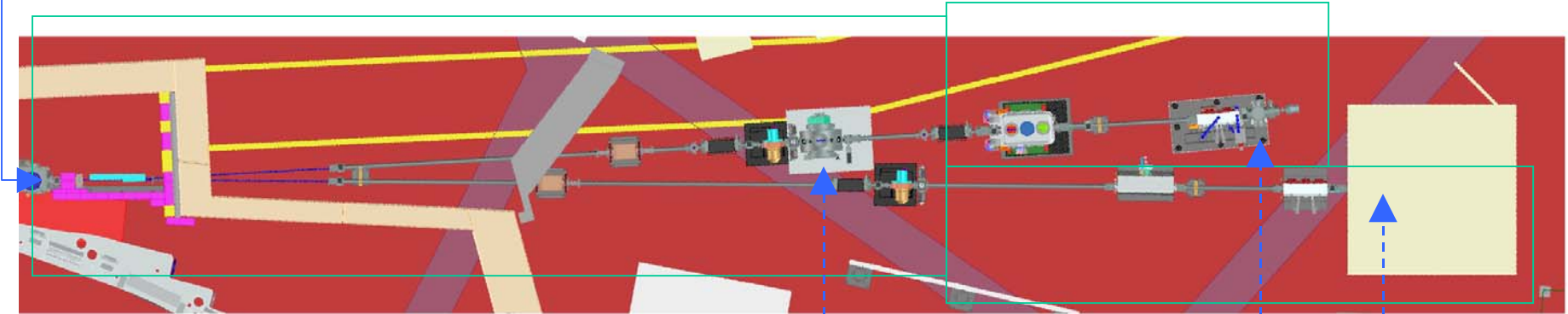
# ALS beamline 6.0



- Slicing of the electron bunch
- In-vacuum undulator

• Separation of fs x-ray pulse

• Grating spectrograph



• Crystal mono

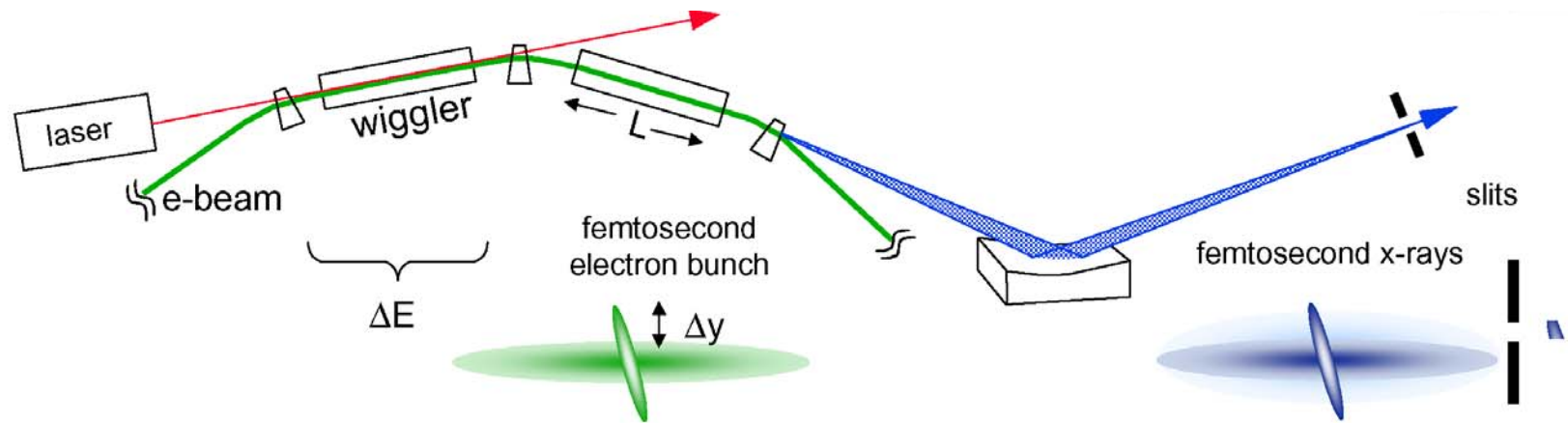
• Laser system  
~ 70 fs, 40 kHz,  
1 mJ, 2 arms

# Goals of beamline design



- Photon energy range  $< 250 \text{ eV} - 10 \text{ keV}$ :
  - Use both undulator and wiggler radiation
  - Use both grating and crystal optics
- Clean separation of fs x-ray pulse
- High efficiency: relatively large angular aperture, limited number of reflections
- Dispersive soft x-ray absorption spectroscopy: grating spectrograph
- Energy resolution:  $0.5 \text{ eV}$  at Ni L edge ( $850 \text{ eV}$ ), for hard x-rays approach perfect crystal limited resolution
- Detectors: high quantum efficiency, gateable
- Laser system: high repetition rate,  $40 \text{ kHz}$ , to increase useable x-ray flux

# Slicing and separation of fs x-rays



- Laser modulation of e-beam energy ( $\Delta E$ )
- Storage ring dispersion ( $\Delta E \rightarrow \Delta y$ )
- Beamline imaging
- Zholents and Zolotarev, Physical Review Letters **76**, 916 (1996),  
Schoenlein et al., Science **287**, 223 (2000).



# Slicing flux



• phase factor  $\eta_1 = 0.1$  (fraction of electrons in optimum phase)

• pulse duration  $\eta_2 = \tau_{\text{laser}} / \tau_{\text{synchrotron}} = 10^{-3}$  ( $\tau_{\text{x-ray}} \approx 170$  fs)  
(70 fs) (70 ps)

• repetition rate  $\eta_3 = f_{\text{laser}} / f_{\text{synchrotron}} = 2 \times 10^{-6}$   
(1 kHz) (500 MHz)

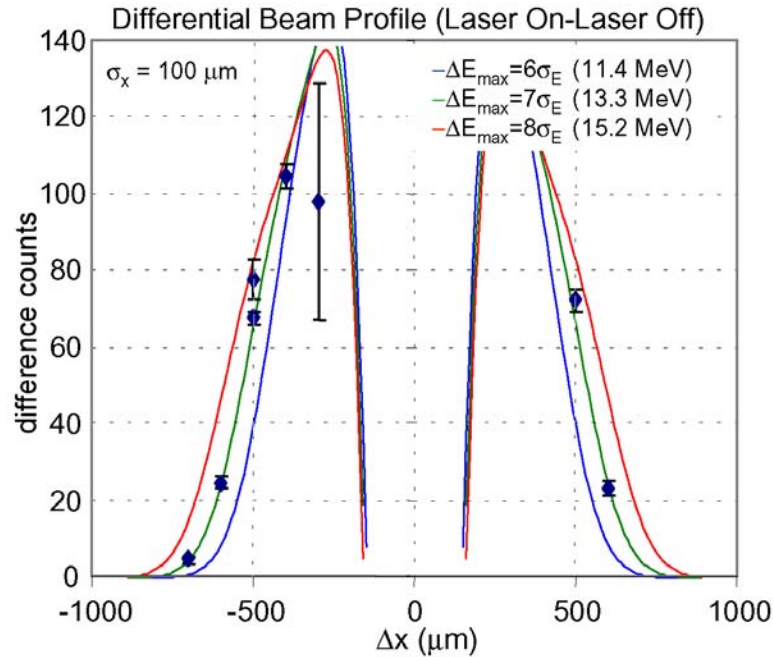
$f_{\text{laser}} / f_{\text{synchrotron}}$   
(40 kHz) (500 MHz)

$$f_{\text{limit}} \approx 3 \times \frac{\text{number of bunches}}{\tau_{\text{damping}}} = 150 \text{ kHz}$$

# Femtosecond x-ray profile

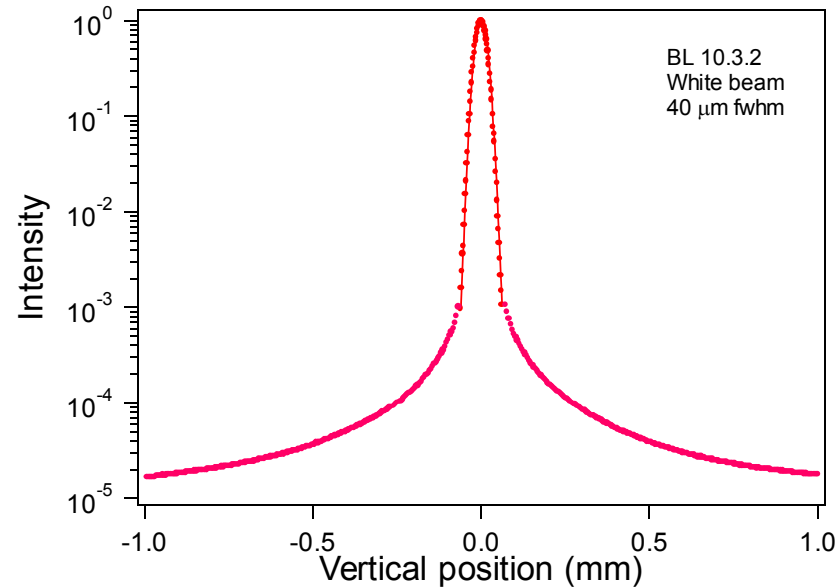


- Measured x-ray profile with slicing



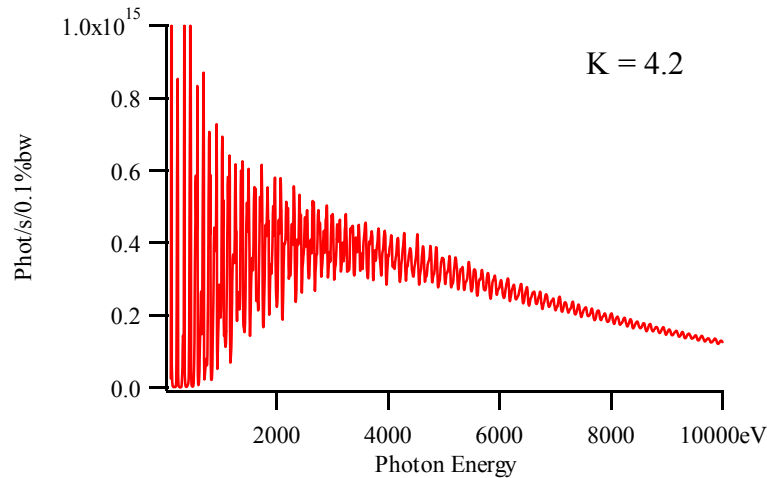
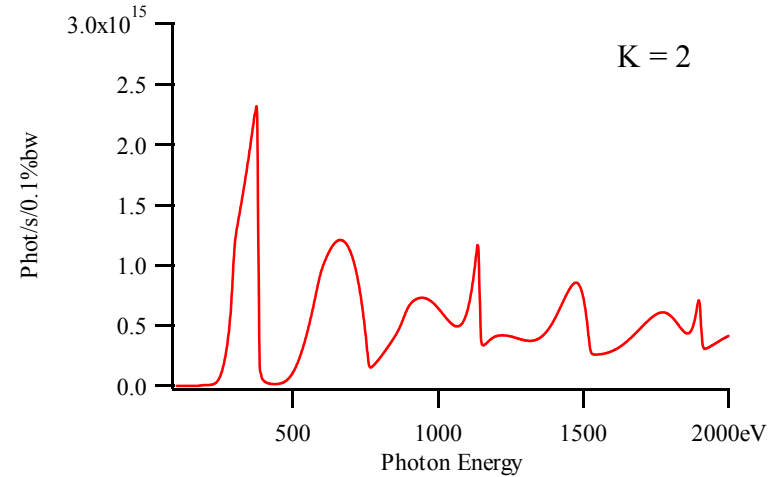
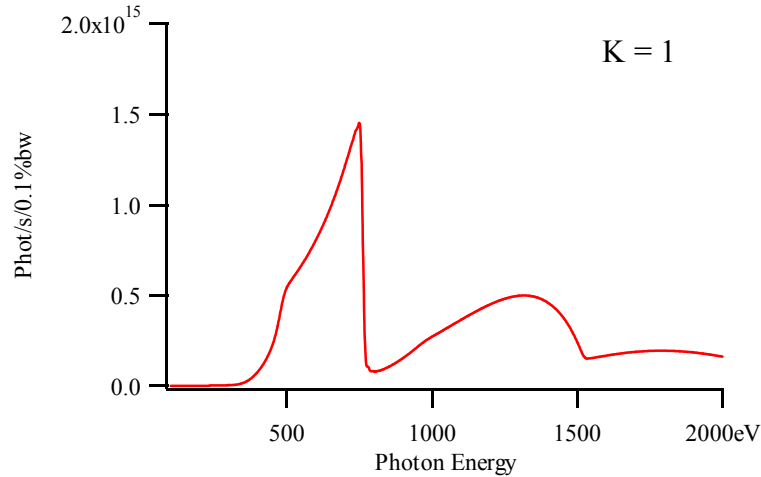
- Laser 0.8 mJ, 75 fs

- Background from optical scattering



- Challenge: isolate fs x-ray intensity of  $10^{-4}$  at displacement of 0.3 mm
- fs signal / 70 ps background, estimate  $\sim 1:1$
- S. Khan (BESSY): scheme to use angular separation of sliced x-ray pulse, with no optic before aperture

# In-vacuum undulator / wiggler source spectrum

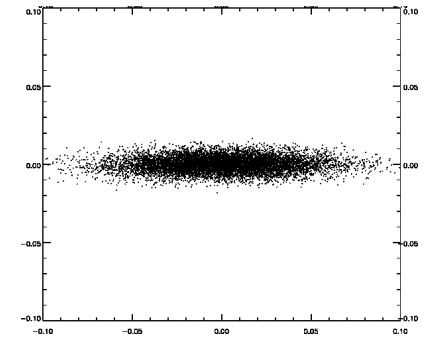
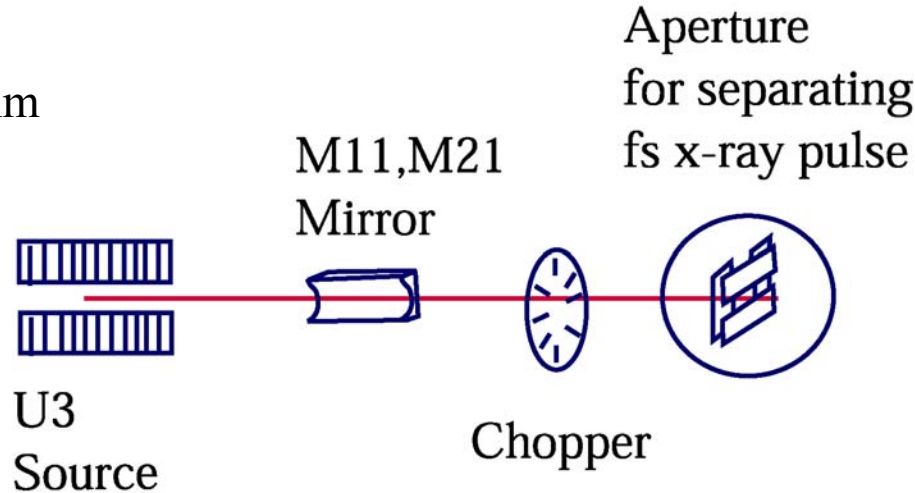
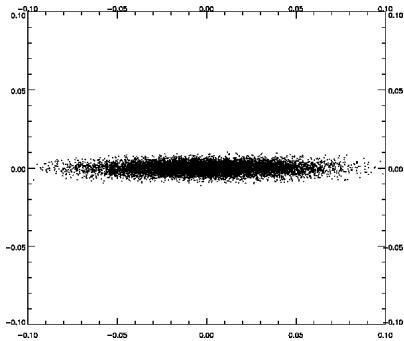


Harmonic	E	$\Delta E$ (fwhm)
1	280 eV	66 eV
2	850 eV	312 eV

- Undulator spectrum calculated with SRW:  $\lambda_u = 3$  cm,  $B(\text{peak}) = 1.5$  T
  - Into 0.5 (h) x 0.5 (v) mrad<sup>2</sup> aperture, use harmonics 1, 2, 3, 4, up to 2 keV
- Wiggler radiation into 0.5 (h) x 0.3(v) mrad<sup>2</sup> aperture, up to 10 keV

# Separation of fs x-ray pulse

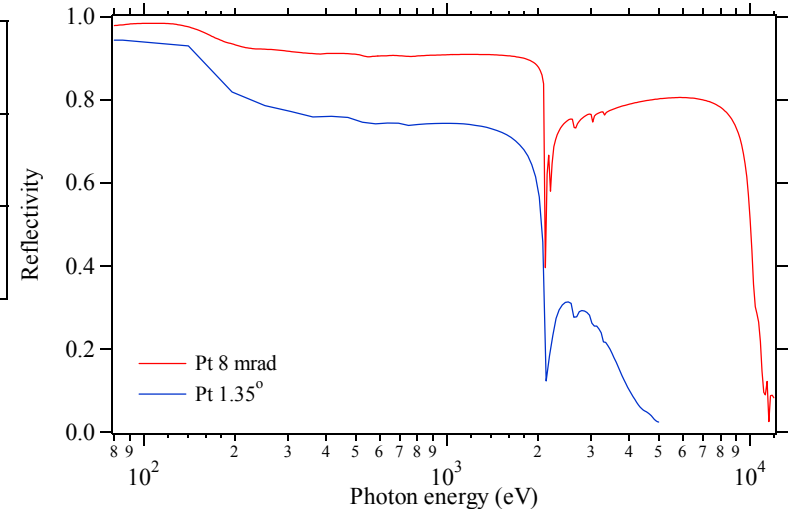
- Source:  
710 (h) x 72  $\mu\text{m}$  (v) fwhm



- Intermediate focus:  
720 (h) x 100  $\mu\text{m}$  (v) fwhm  
70  $\mu\text{m}$  (v) for central cone

	Type	Coating and blank material	Dimensions (mm)	Radius (m)	Incidence angle ( $^\circ$ )
M11	Toroidal mirror	Pt-coated silicon	320 x 90 x 25	449 (R) 0.2472 ( $\rho$ )	88.6552
M21	Toroidal mirror	Pt-coated silicon	800 x 40 x 75	1458 (R) 0.0933 ( $\rho$ )	89.54

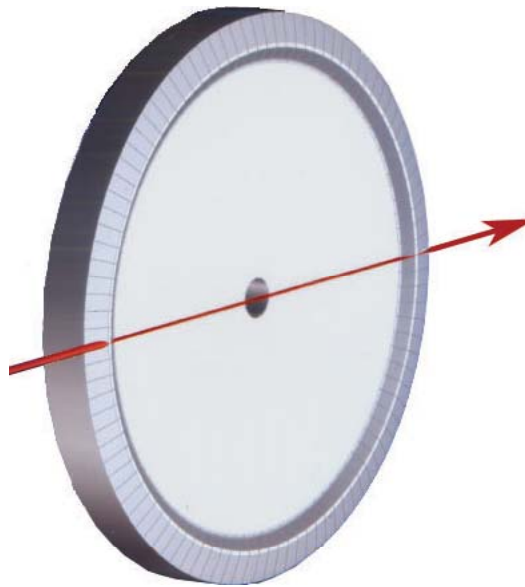
- Single reflection in sagittal focusing reduces x-ray scattering background



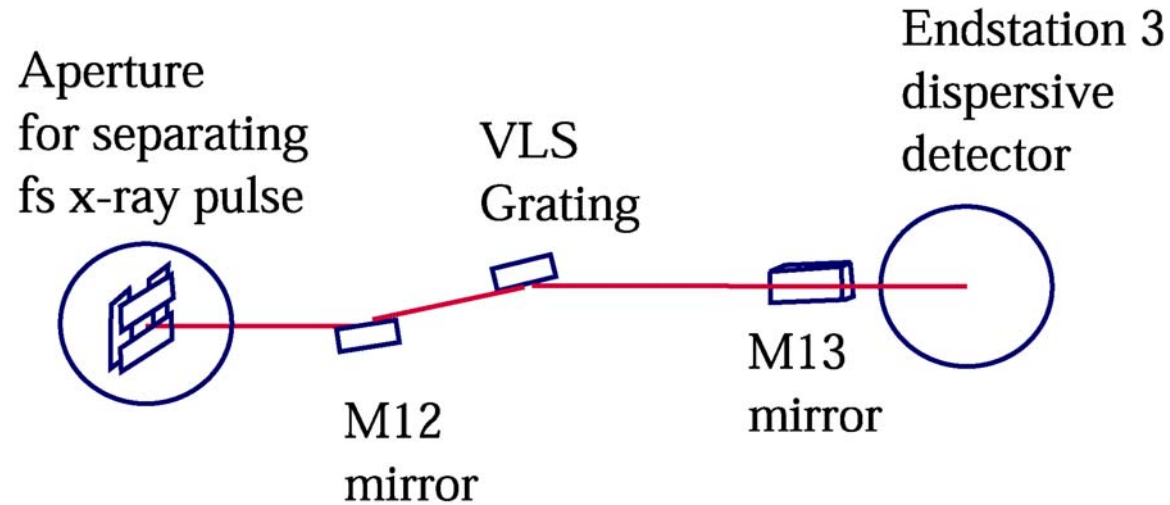
# X-ray chopper



- Absorbed power: 430 W on hard x-ray branch, reduces power on samples in pink beam and on downstream optics
- Frequency: 40 kHz matched to laser repetition rate
- Acceptance: 2 %
- Design based on Rigaku rotating anode



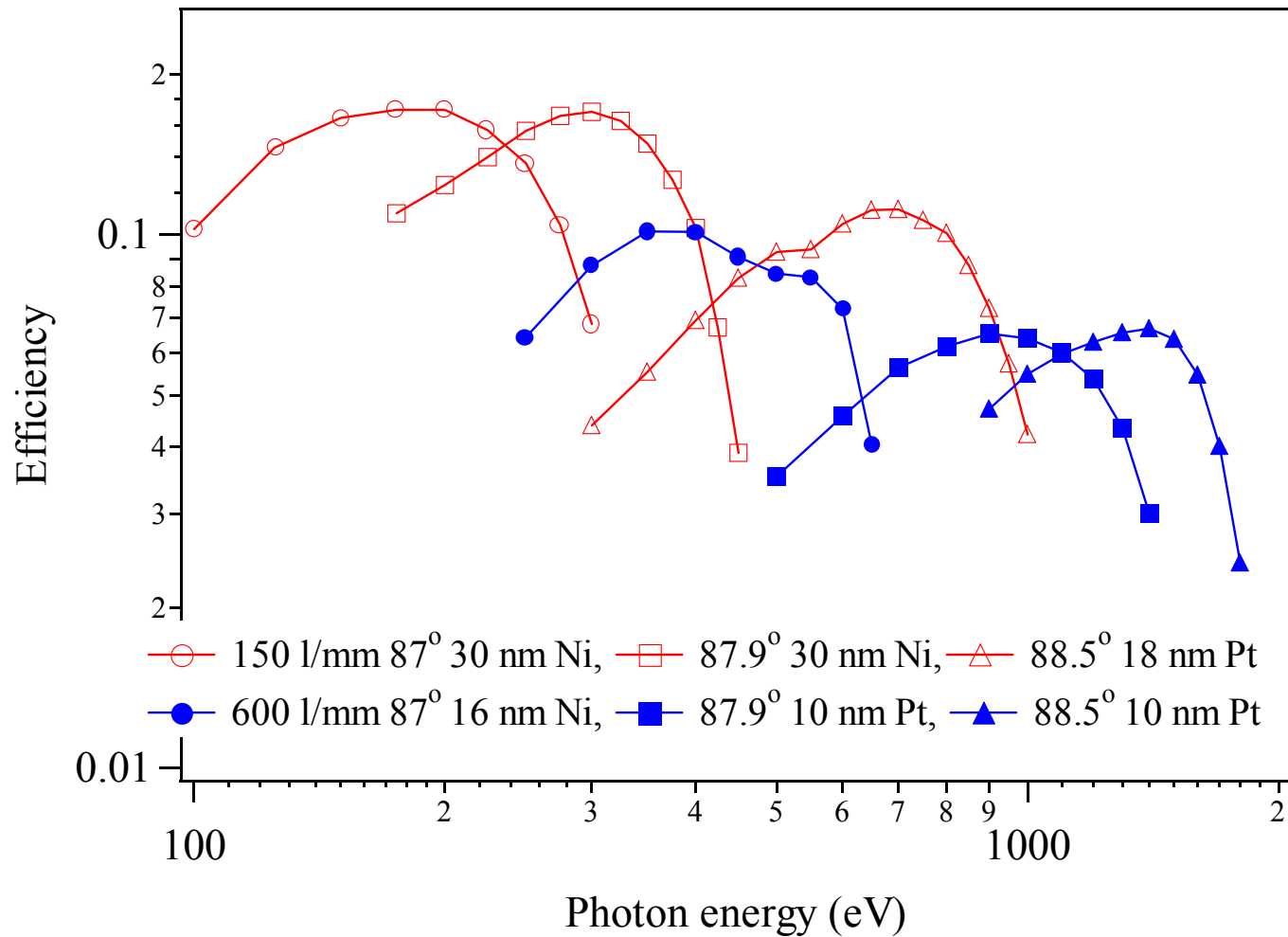
# Grating spectrograph



	Type	Coating and blank material	Dimension (mm)	Radius (m)	Incidence angle(°)	Grating period
M12	Spherical mirror	Ni, Pt-coated silicon	60x70x25 77x70x25 100x70x25	63 90 126	87 87.9 88.5	-
G1,G2	VLS, Plane grating	Ni, Pt-coated silicon	167x36x30	$\infty$	84 – 90	1/150, +1 1/600, +1
M13	Plane elliptic mirror	Pt-coated fused silica	240 x 40 x 25	29.5	88.5	-

- VLS grating produces flat field spectrum at detector

# Efficiency of grating spectrograph



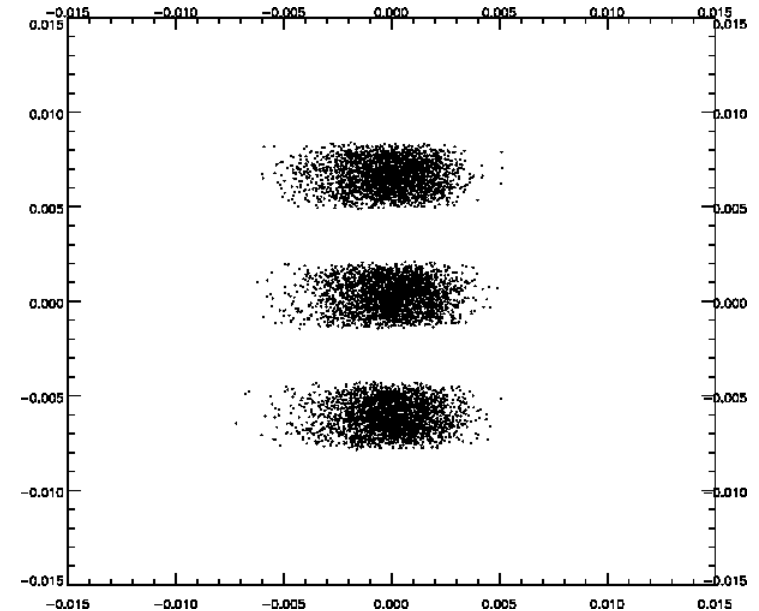
- Includes grating efficiencies from Nevire code and M11, M12 and M13 reflectivities

# Energy resolution at 850 eV, range of spectrum across detector



- Goals:
  - Energy resolution match core hole linewidths, 0.5 eV at Ni L edge
  - Energy range for XAS across detector, 60 eV at C K edge
- Parameters:
  - Size of spectrograph:  $r = r' = 3$  m
  - Entrance slit matched to beam fwhm (for undulator central cone)
  - Detector: 25  $\mu\text{m}$  spatial resolution, 10 mm slit length (based on streak camera)
  - M12 magnification 1

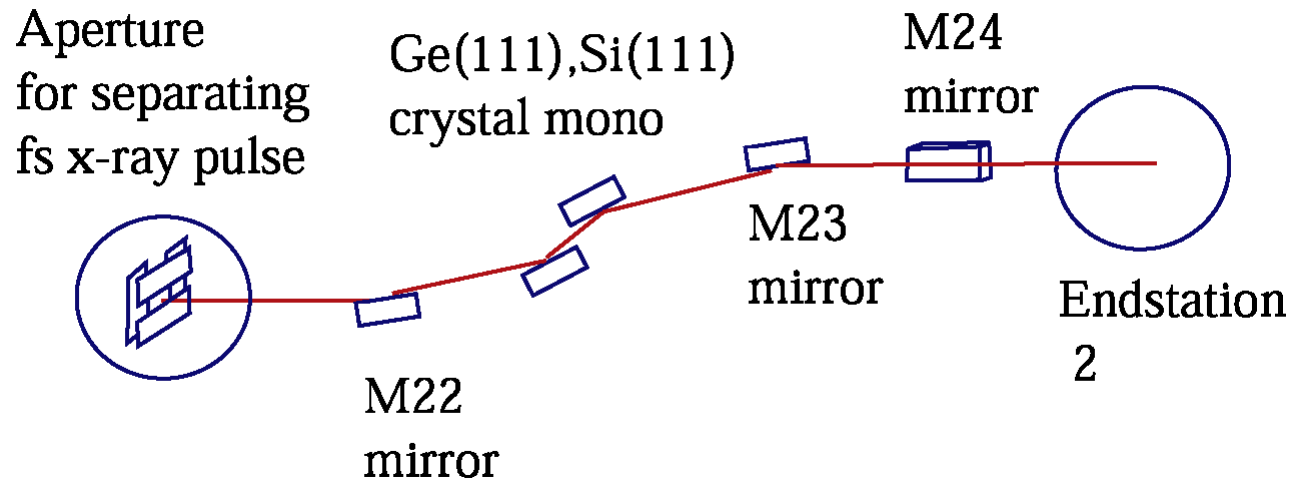
Photon energy	Grating(l/mm), m, $\theta$	Energy resolution	Energy range
280 eV	150, +1, $87.9^\circ$	0.27 eV	64 eV
850 eV	600, +1, $87.9^\circ$	0.56 eV	160 eV



- Photon energies 849, 850, and 851 eV, 600 l/mm grating and 60  $\mu\text{m}$  entrance slit.

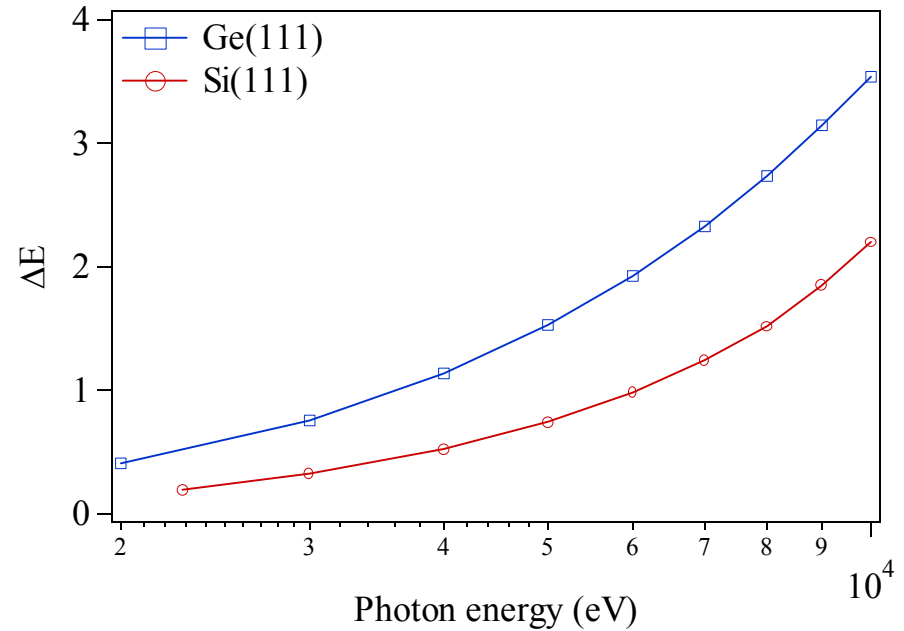
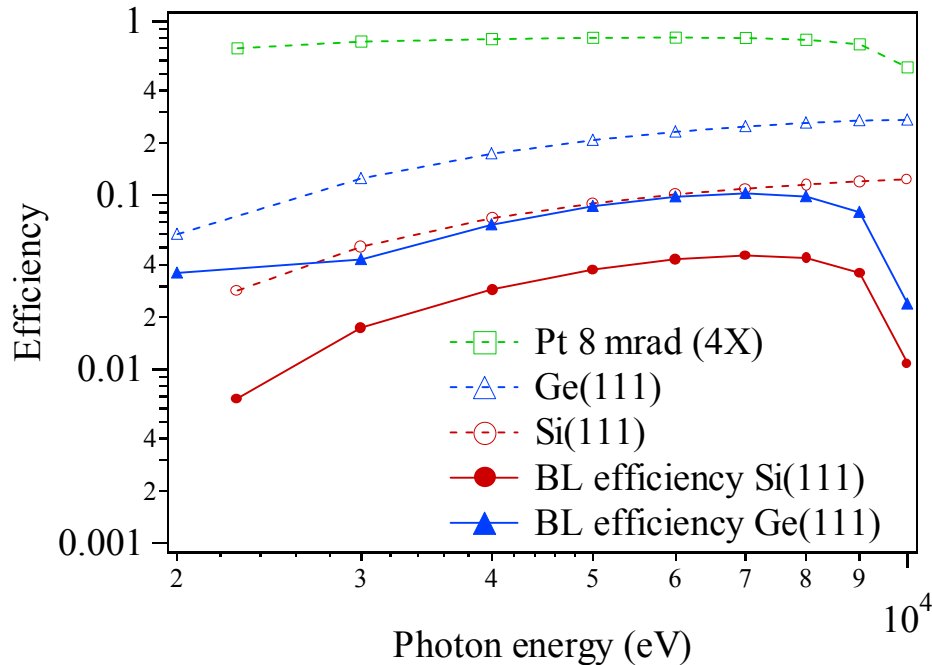


# Crystal monochromator



	Type	Coating and blank materia	Dimensions (mm)	Radius (m)	Incidence angle(°)
M22	Cylindrical mirror	Pt-coated silicon	150 x 12 x 6	750	89.54
X1, X2	Crystal	Si (111), Ge(111)	20 x 10 x 10	$\infty$	6 - 60 ( $\theta_E$ )
M23	Cylindrical mirror	Pt-coated silicon	150 x 12 x 6	750	89.54
M24	Plane elliptical mirror	Pt-coated fused silica	600 x 40 x 50	160	89.54

# Efficiency and energy resolution of crystal monochromator branchline



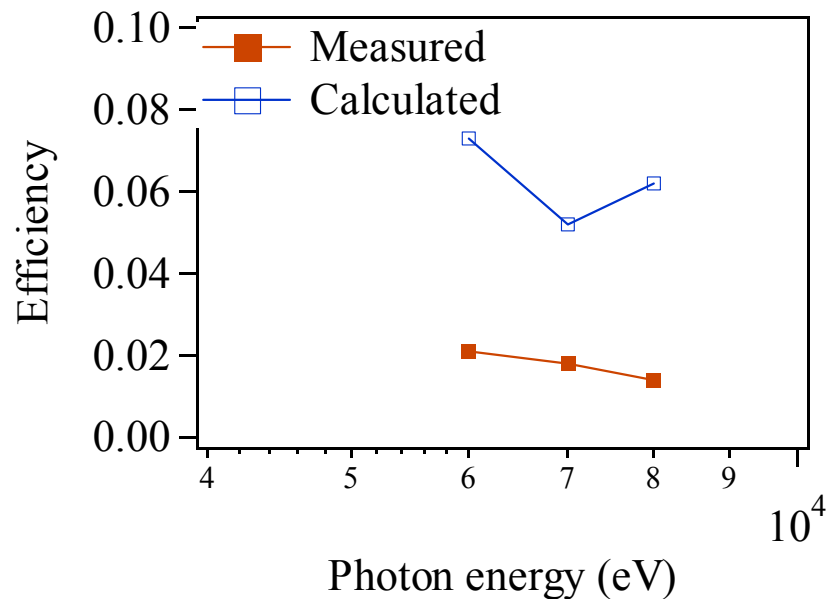
- Crystal efficiency calculated from  $\epsilon = (1/\tan\theta) \int R^2(\theta) d\theta$
- Normalized to 0.1 % bandwidth
- Ge(111) crystals for sliced beam, Si(111) for full beam +/- 11  $\mu\text{rad}$  thermal distortion

- Contributions
  - Crystal rocking widths: Si(111) 54  $\mu\text{rad}$ , Ge(111) 125  $\mu\text{rad}$  at 5 keV
  - Collimation of M22 mirror:  $s/r = 106 \mu\text{m}/3 \text{ m} = 35 \mu\text{rad}$ ,

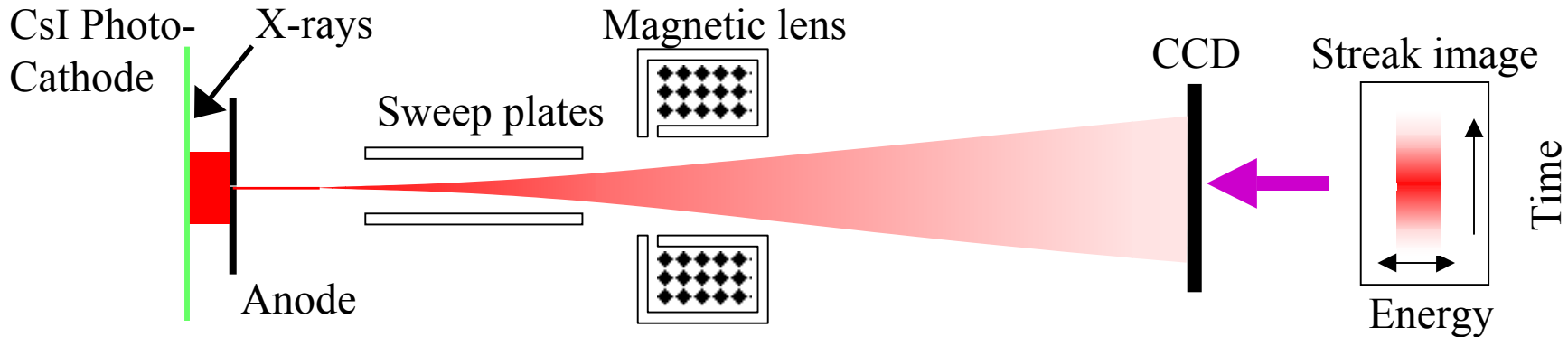
# Hard x-ray dispersive XAS



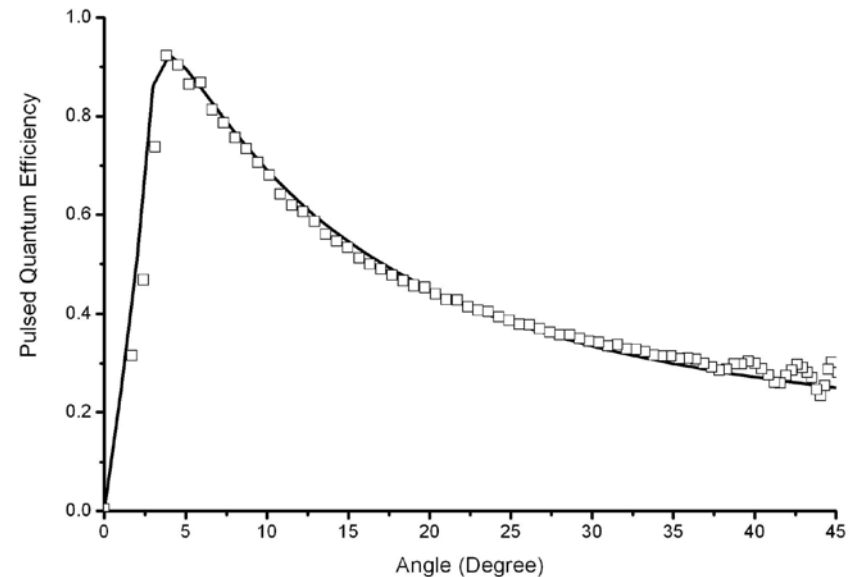
- Goal: with hard x-rays take advantage of wide bandwidth of wiggler, take whole EXAFS spectrum in parallel
- Crystal polychromator not a solution, each part of crystal diffracts narrow bandwidth
- Multilayer grating have demonstrated high efficiency 34% at 8 keV, limited bandwidth, Martynov et al. SPIE (1997)
- Total external reflection gratings
  - Tests on an available laminar grating: 380 l/mm, 12 nm groove depth, nickel coating, measured at  $\theta_g = 0.4$  degrees
  - Efficiency may be limited by surface roughness



# Detectors: Streak Camera



- X-ray streak cameras achieved resolution of  $\Delta t \sim 700$  fs in averaging mode
- Combined with slicing the streak camera could suppress the background because most ps x-rays will be swept to a different position on the time axis
- High quantum efficiency by using grazing incidence to match x-ray penetration depth and electron escape depth
- Quantum efficiency of CsI vs  $\theta$  at 500 eV, D. Lowney et al. SPIE 5194b (2003)



# Summary



- Time-resolved x-ray absorption spectroscopy, example of liquid carbon
- Source: in-vacuum undulator / wiggler
- Beamline optimized for TR XAS
  - Separation of slicing fs x-ray pulses: sagittal focusing toroidal mirrors
  - Grating spectrograph: measure entire x-ray absorption spectrum simultaneously
  - Crystal monochromator: using Ge(111) and Si(111) crystals
- Detectors: grazing-incidence streak camera and avalanche photodiodes
- Schedule:
  - Insertion device, Soft x-ray branchline, Laser system: Jan. 2005
  - Hard x-ray branchline: Sept. 2005
- Poster: R. Schoenlein (today 6.94)